

REMARKS

Applicants appreciate the thoroughness with which the Examiner has examined the above-identified application. Reconsideration is requested in view of the amendments above and the remarks below.

For purposes of appeal, claims 1 and 12 have been amended for clarification purposes only. It is submitted that these amendments would not require a further search of the art since the pending limitations have already been searched.

No new matter has been added.

Rejection under 35 USC § 112, first paragraph

The Examiner has rejected amended claim 13 under 35 U.S.C. 112, first paragraph, stating that the specification does not reasonably provide enablement for the solvent being "aliphatic hydrocarbons, aromatic hydrocarbons, naphthenic hydrocarbons and combinations thereof" to dissolve the claimed salts. The Examiner takes the position that the solvents recited in claim 13 are NOT polar solvents, and as such, cannot dissolve salts, which are ionic (polar) compounds.

Applicants disagree and submit a partial printout of the URL "umanitoba.ca/chemistry/courses/chem222/.../solvents_and_reagents.pdf," which is a chemistry guide for students, attached hereto as Appendix D. As is described in this chemistry guide, hydrocarbon solvents will dissolve low polarity organics. Salts, including at least some of those listed in claim 12, are known to be low polarity organics.

Specification and Claim Objections

The Examiner continues to object to the specification and claim 12 stating that the recitation of a 'soluble salt, such as KOH' is "not a proper term for KOH, since by definition the salt is "a compound, that results from replacement of the acid hydrogen of an acid by a metal or a group acting like a metal" citing (Merriam-Webster's Collegiate Dictionary, tenth edition, page 1032).

Applicants continue to disagree with the Examiner, and once again, submit that it is common knowledge that alkalis are basic ionic salts of an alkali metal (PH value of greater than 7) of which a common example is potassium hydroxide (i.e., KOH which is often called "potash"). To support applicants' position, attached hereto are copied pages from the *CRC Handbook of Chemistry and Physics*, 66th Ed., CRC Press, Inc. 1985, pgs. D-1—and D-107 (Appendix A) and a general chemistry book entitled *Chemistry*, James P. Birk, Houghton Mifflin Company, 1994, pg. 103 (Appendix B), both which establish that that KOH is in fact a salt. It is submitted that TEAH, TBAH and TMAH are also salts, in particular, quaternary ammonium salts, as is supported by the Internet printouts attached hereto as Appendix C, as well as is supported by the Examiner's 103 rejection with respect to Sachdev (U.S. Publication No. 2002/0000239).

With respect to the terms "1,4-dioxane" and "organic surfactant" in claim 12, applicants have canceled such limitations for purposes of expediting allowance of the present application.

It is for these reasons that applicants submit that both the specification and the claims are in a condition for allowance.

Claim Rejections under 35 USC § 103

Stephanie et al (U.S. Patent No. 5,891,257).

The Examiner has rejected claims 1-4, 6, 7, and 9 under 35 U.S.C. 103 (a) as being obvious over Stephanie et al (U.S. Patent No. 5,891,257).

Independent claim 1, from which claims 2-4, 6, 7 and 9 depend, is directed to locally removing polymer sealant from a semiconductor device by providing a component having a thermoset polymer sealant on a surface thereof and detecting the thermoset polymer sealant on a portion of such surface. Bulk thermoset polymer sealant is removed, and residual thermoset polymer sealant remaining on such portion of the surface is detected after the bulk thermoset polymer sealant has been removed. The substrate is heated to a temperature under the boiling point of the solvent of the solution, and a depolymerization cleaning solution is locally applied substantially only to the residual thermoset polymer sealant in an amount sufficient to at least cover the residual thermoset polymer sealant. An essential feature of the invention is that this depolymerization cleaning solution is a salt saturated solution having surfactant. The residual thermoset polymer sealant is contacted with the present depolymerization cleaning solution to chemically degrade such residual thermoset polymer sealant for the removal thereof. The degraded residual thermoset polymer sealant is then removed from the surface of the component.

Applicants continue to submit that Stephanie et al. discloses a tool 12 with a flow head 14 having a support 22 with an opening 22' adapted to contact a circuit board and

flow solvent to the surface of the board. (Col. 3, II. 33-46 and FIG. 3.) An opening 24' of a solvent nozzle 24 is used to apply solvent to the circuit board using scrubbing action during application of the solvent. (Col. 3, II. 50-57.)) In Stephanie et al., the solvent is heated, the support 22 contacts the substrate assembly, the solvent flows over the encapsulated chip 30' and the flow head 14 is lowered to remove encapsulation. (Col. 7., I. 62 to col. 8, I. 13-25.) In accordance with Stephanie et al., the scrubbing action is effective in removing the resin from the particular intended device. (Col. 5, II. 2-4.)

Applicants continue to submit that Stephanie et al. does not disclose, contemplate or suggest that its *cleaning solution* is a salt saturated solution having surfactant, as is claimed. Rather, Stephanie et al. is limited to unsaturated solutions of an alcohol, an acid, and an organic solvent. (Col. 8, II. 43-55.) The solvent comprises 10-100 parts of a primary alcohol and 0-90 parts of a less polar organic solvent as exemplified by benzyl alcohol, xylene, toluene; and one to ten parts of an organic acid as exemplified by methanesulfonic acid, p-toluenesulfonic acid and trifluoromethanesulfonic acid. Additionally, about 30 parts of ethylene glycol is used in the solvent, and optionally a surfactant and/or or a corrosion inhibitor. (Col. 9, II. 18-28.)

It is the Examiner's position that the cleaning solution of the present invention becomes unsaturated as soon as it is heated, and as such, applicants' cleaning solution is no different than that disclosed in Stephanie et al. Applicants disagree.

An essential feature of the invention is that the present cleaning solution is saturated with salt. That is, applicants' cleaning solution has a high concentration of salt (solute) –to the point that the solution can hold no more salt (i.e., it is saturated). Once the

temperature of the cleaning solution is increased, even though the solubility of the solution may vary, the initial increased concentration or amount of salt in solution remains the same. Stephanie et al. does not disclose, contemplate or suggest that its initial cleaning solution (i.e., before heating) is a saturated solution, and as such, does not have as high a concentration of solute in solvent as does the cleaning solution of the present invention, which again, is a saturated solution. The saturated cleaning solution of the invention is different than the unsaturated cleaning solution of Stephanie et al. To support this position, applicants point out that Stephanie et al. discloses that a scrubbing action via nozzle 24' is used in combination with its solvent for the effective removal of the resin. (Col. 5, ll. 2-4, and col. 5, l. 65 to col. 6, l. 2.) In accordance with the present invention, all that is needed for the effective removal of the residual polymer is applicants' saturated cleaning solution.

Applicants also continue to submit that Stephanie et al. does not disclose, contemplate or suggest the steps of first removing bulk thermoset polymer sealant and then detecting any residual thermoset polymer sealant for the removal thereof, as is currently claimed. The Examiner states that these steps would be within the skill of the art at the time of the invention, however, it is submitted that hindsight and the level of ordinary skill in the art may not be used to supply a component missing from the prior art references. *Al-Site Corp. v. VSI International, Inc.*, 174 F.3d 1308, 1324, 50 USPQ2d 1161, 1171 (Fed. Cir. 1999).

It is respectfully submit that the claims of the instant invention include limitations not disclosed nor contemplated by Stephanie et al. such that Stephanie et al. does not render obvious the instant invention.

Sachdev (U.S. Publication No. 2002/0000239)

The Examiner has also rejected claims 1, 7, 9, 10, 11, and 14 under 35 U.S.C. 103 (a) as being obvious over Sachdev (U.S. Publication No. 2002/0000239).

The Examiner states that Sachdev discloses a stripping solution comprising 0.05-0.5% of a non-ionic surfactant, 0.5-5% of tetralkylammonium hydroxide (the Examiner states that this reads on TEAH, and as such, conflicts with the Examiner's claim and specification objections in the above office action) and a solvent, wherein the solution causes the disintegration of a polymer [0053]. Like that of Stephanie et al., applicants continue to submit that Sachdev does not disclose, contemplate or suggest that its stripping *solution* is a salt saturated solution having surfactant, as is claimed. On the contrary, the tetraalkyl ammonium hydroxide does not saturate the solution. It is only present in an effective amount of about 0.5-5% by weight based on anhydrous material. (Sachdev, Paragraph [0053].) The stripping solution of Sachdev is an unsaturated solution, having a lower concentration of salt as compared to the saturated solution of the invention. As such, the depolymerization cleaning solution of the invention is technically different and distinct from the stripping composition of Sachdev.

With respect to claim 7, the Examiner states that "about 25 minutes," as claimed, permits some tolerance, and therefore, the time disclosed by Sachdev for the cleaning "about 30 minutes" is close and is therefore obvious. To support the Examiner position,

the Examiner cites *Titanium Metals Corp. v. Banner*, 778 F.2d 775,783,227 USPO 773,779 (Fed. Cir. 1985) for the proposition that a prima facie case of obviousness exists when the claimed range and the prior art are close enough such that one skilled in the art would have expected them to have the same properties. However, applicants point out that in *Titanium Metals*, the claimed composition consists of 0.3% Mo and 0.8% Ni while the prior art included 0.25% Mo - 0.75% Ni and 0.31% Mo - 0.94% Ni. The Court in *Titanium Metals* found that these "proportions are so close that prima facie one skilled in the art would have expected them to have the same properties. *Id.* The case at hand is much different than that of *Titanium Metals*. The "proportions" or time range of the present invention ranging from about 5 minutes to about 25 minutes (claim 7) is much different than the time range of Sachdev from 30 minutes to 8 hours (for 30 minutes up to about 2 hours to 8 hours, or more typically for about 60 to 90 minutes, Sachdev, Paragraphs [0026] and [0062].) This is a difference in kind and not a difference in degree. *Becket v. Coe* 38 USPQ 26 (CADC 1938); *In re Becket et al.* 33 USPQ 33 (CCPA 1937), *In re Russell* 169 USPQ 426 (CCPA 1971). The prior art time range is not close enough to that of the present invention. *Titanium Metals Corp.*, 778 F.2d at 783, 227 USPO at 779

Applicants also submit that Sachdev does not disclose, contemplate or suggest the steps of first removing bulk thermoset polymer sealant and then detecting any residual thermoset polymer sealant for the removal thereof, as is currently claimed. Applicants again submit that hindsight and the level of ordinary skill in the art may not be used to supply a component missing from the prior art references. *Al-Site Corp.*, 174 F.3d at 1324, 50 USPQ2d at 1171 (Fed. Cir. 1999).

It is respectfully submit that the claims of the instant invention include limitations not disclosed nor contemplated by Sachdev such that Sachdev does not render obvious the instant invention.

Stephanie in combination with Sachdev

The Examiner has also rejected claim 12 under 35 U.S.C. 103(a) as being unpatentable over Stephanie in combination with Sachdev. Applicants disagree

Claim 12, which is ultimately dependent upon claim 1, is directed to components of the instant depolymerization cleaning solution of a salt saturated solution having surfactant. The Examiner recognizes that the solvents recited in claim 12 are not specifically recited in Sachdev. To overcome this deficiency the Examiner states that Stephanie utilizes glycols along with t-butyl alcohol, thus providing the motivation to use one in lieu of the other, and the use of t-butyl alcohol is obvious over the use of n-butyl alcohol, as being structural isomer, and therefore having similar functional characteristics, as per *In re Wilder*, 563 F.2d 457, 460,195 USPQ 426, 429 (CCPA 1977).

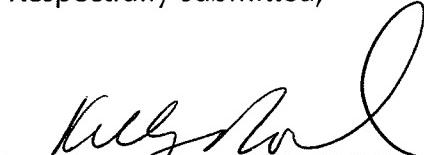
However, applicants again submit that neither Stephanie et al. nor Sachdev, alone or in combination, disclose, contemplate or suggest a depolymerization cleaning solution of a salt saturated solution having surfactant, as is currently claimed. Rather, the cleaning solutions of both Stephanie et al. and Sachdev are limited to unsaturated solutions, and as such, have less solute in the solution as compared to the solution of the present invention, which is saturated.

In view of the foregoing, applicants submit that neither Stephanie et al. nor Sachdev, alone or in combination, disclose or suggest doing what applicants have done, such that applicants' invention is unobvious and would only be found based on applicants' own disclosure, which, of course, is improper as a hindsight reconstruction of applicants' invention. *W.L. Gore & Assoc. v. Garlock*, 721 F.2d 1540, 1553 [220 USPQ 303, 312-13] (Fed. Cir. 1983). Any contrary conclusion would be based on hindsight. *Al-Site Corp.*, 174 F.3d at 1324, 50 USPQ2d at 1171.

In view of the above remarks, applicants submit that the present invention would not have been obvious to one of ordinary skill in the art at the time of the invention under section 103.

It is respectfully submitted that the application has now been brought into a condition where allowance of the entire case is proper. Reconsideration and issuance of a notice of allowance are respectfully solicited. Should the Examiner not find the claims to be allowable, Applicants' attorney respectfully requests that the Examiner call the undersigned to clarify any issue and/or to place the case in condition for allowance.

Respectfully submitted,



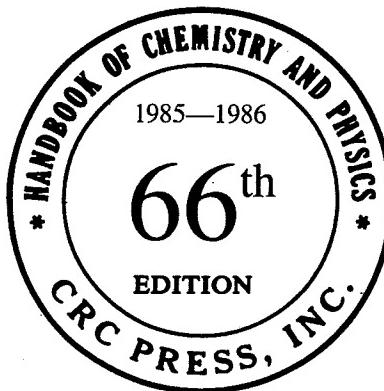
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Appendix A

CRC Handbook of Chemistry and Physics

A Ready-Reference Book of Chemical and Physical Data



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In collaboration with a large number of professional chemists and physicists whose assistance is acknowledged in the list of general collaborators and in connection with the particular tables or sections involved.



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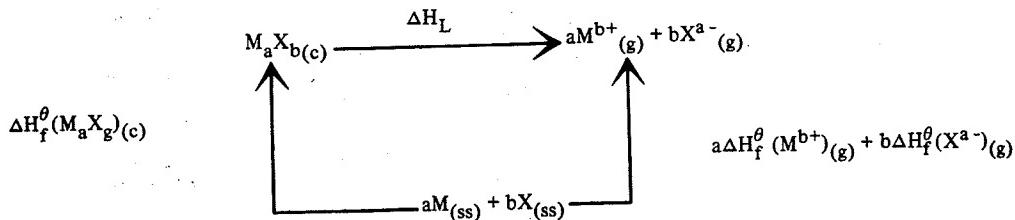
CODATA RECOMMENDED KEY VALUES FOR THERMODYNAMICS, 1977
 (To convert joules to calories multiply by 0.239006) (continued)

Substance	State	ΔH° (298.15 K) kJ·mol ⁻¹	S° (298.15 K) J·K ⁻¹ ·mol ⁻¹	H° (298.15 K) – H° (0) kJ·mol ⁻¹
Ca	cr	0	41.6 ± 0.4	5.73 ± 0.04
Ca	g	177.8 ± 0.8	154.775 ± 0.020	6.197 ± 0.002
Ca ²⁺	aq	-543.10 ± 0.80	-56.4 ± 0.4	—
CaO	cr	-635.09 ± 0.90	38.1 ± 0.4	6.75 ± 0.06
Li	cr	0	29.12 ± 0.20	4.632 ± 0.040
Li ⁺	aq	-278.455 ± 0.090	11.30 ± 0.35	—
Na	cr	0	51.30 ± 0.20	6.460 ± 0.020
Na ⁺	aq	-240.300 ± 0.065	58.41 ± 0.20	—
K	cr	0	64.68 ± 0.20	7.088 ± 0.020
K ⁺	aq	-252.17 ± 0.10	101.04 ± 0.25	—
Rb	cr	0	76.78 ± 0.30	7.489 ± 0.020
Rb ⁺	aq	-251.12 ± 0.13	120.46 ± 0.40	—
Cs	cr	0	85.23 ± 0.40	7.711 ± 0.020
Cs ⁺	aq	-258.04 ± 0.13	132.84 ± 0.40	—

LATTICE ENERGIES

H. D. B. Jenkins

Table 1 contains calculated values of lattice energies, U_{pot} , of crystalline salts M_aX_b . U_{pot} is expressed in the units of kilojoules per mole, kJ mol^{-1} . M and X can be complex or simple ions. Also cited is the lattice energy obtained from the Born-Fajans-Haber Cycle, U_{BFHC}^θ , using thermochemical data published in U.S. Government publications plus certain other data which are located at the end of this table. The values quoted are of variable reliability and a full discussion of the values is to appear in a review by Jenkins and Waddington currently (1978) nearing completion.



where, (ss) is the standard state of the ion or element

$$\Delta H_L^{\theta} = U_{pot}(M_aX_b) + \left[a\left(\frac{n_{M^{b+}}}{2} - 2\right) + b\left(\frac{n_{X^{a-}}}{2} - 2\right) \right] RT$$

$$\Delta H_L^{\theta} = a\Delta H_f^{\theta}(M^{b+}) + b\Delta H_f^{\theta}(X^{a-}) - \Delta H_f^{\theta}(M_aX_b)$$

Where $n_{M^{b+}}$, $n_{X^{a-}}$ is equal to 3 for monatomic ions, 5 for linear polyatomic ions, and 6 for polyatomic nonlinear ions.

The data listed in Table 2 were employed in the calculation of the Born-Haber Cycle values in Table 1 and are not listed in Technical Notes 270 of the National Bureau of Standards.

		ThH ₃	PtH ₃	AmH ₃	Ref.
Finch, Gates, Jenkinson (1972)					Gibb (1962)
Finch, Gates, Jenkinson (1972)	685				Gibb (1962)

Table 1 (continued)
LATTICE ENERGIES

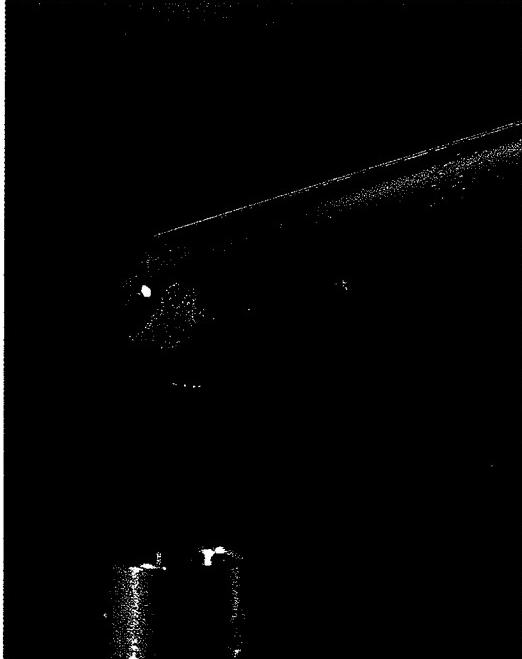
Element	Calculated lattice energy (kJ/mol ⁻¹)	Thermochemical cycle lattice energy (kJ/mol ⁻¹)		Calculated lattice energy (kJ/mol ⁻¹)	Thermochemical cycle lattice energy (kJ/mol ⁻¹)		Calculated lattice energy (kJ/mol ⁻¹)	Thermochemical cycle lattice energy (kJ/mol ⁻¹)	
		Literature source	Salt		Literature source	Salt		Literature source	Salt
TiH ₂	2866	Gibb (1962)	2845	CuOH	1006	Karapet'yants (1954)	—	—	—
2rH ₂	2711	Gibb (1962)	2999	AlOH	918	Karapet'yants (1954)	—	—	—
CuH ₂	2941	Karapet'yants (1954)	—	AuOH	1033	Karapet'yants (1954)	—	—	—
ZnH ₂	2870	Karapet'yants (1954)	—	TlOH	705	Karapet'yants (1954)	—	—	—
HgH ₂	2707	Karapet'yants (1954)	—	Zn(OH) ₂	2795	Yatsimirskii (1961)	—	—	3158
AlH ₂	5924	Karapet'yants (1954)	—	Ce(OH) ₃	2607	Yatsimirskii (1961)	—	—	2918
FeH ₂	5724	Gibb (1962)	—	He(OH) ₂	2669	Karapet'yants (1954)	—	—	—
ScH ₂	5439	Gibb (1962)	—	Sn(OH) ₂	2489	Yatsimirskii (1961)	—	—	2729
YH ₂	5063	Gibb (1962)	—	Pe(OH) ₂	2376	Yatsimirskii (1961)	—	—	2623
LaH ₂	4895	Gibb (1962)	—	Sc(OH) ₂	5063	Karapet'yants (1954)	—	—	—
FeH ₂	5724	Gibb (1962)	—	Y(OH) ₂	4707	Karapet'yants (1954)	—	—	—
GeH ₂	5690	Gibb (1962)	—	La(OH) ₂	4443	Karapet'yants (1954)	—	—	—
InH ₂	5092	Gibb (1962)	—	Cr(OH) ₂	5556	Karapet'yants (1954)	—	—	—
TiH ₂	5092	Yatsimirskii (1956)	—	Min(OH) ₂	6213	Wen, Sho (1975)	—	—	—
KHS	644	Yatsimirskii (1956)	—	Al(OH) ₂	5627	Karapet'yants (1954)	—	—	—
RbHSe	623	Yatsimirskii (1956)	—	Ca(OH) ₂	5732	Karapet'yants (1954)	—	—	—
CsHSe	598	Yatsimirskii (1956)	—	Ind(OH) ₂	5280	Karapet'yants (1954)	—	—	—
Hydrogenides	—	—	—	Tl(OH) ₂	5314	Karapet'yants (1954)	—	—	—
LiHS	703	Yatsimirskii (1956)	—	Ti(OH) ₂	9436	Karapet'yants (1954)	—	—	—
NaHS	704	Yatsimirskii (1956)	—	Zr(OH) ₂	8619	Karapet'yants (1954)	—	—	—
KHS	650	Waddington (1959)	821	Min(OH) ₂	10933	Brenet, Goellier, Cabano (1963)	—	—	—
RbHS	623	Waddington (1959)	747	Sn(OH) ₂	9188	Karapet'yants (1954)	—	—	—
CsHS	582	Waddington (1959)	—	Imidates	—	—	—	—	—
NH ₂ HS	661	Yatsimirskii (1956)	639	CaNH	3293	Altshuller (1955)	—	—	—
Ca(HS) ₂	2184	Yatsimirskii (1956)	637	SrNH	3146	Altshuller (1955)	—	—	—
Si(HS) ₂	2063	Yatsimirskii (1956)	595	BaNH	2975	Altshuller (1955)	—	—	—
Be(HS) ₂	1979	Yatsimirskii (1956)	666	Metanobrates	—	—	—	—	—
LiOH	1021	Saloman (1970)	1039	NaNbO ₃	789	Lapiskii, Nebyhysyn (1961)	—	—	—
NaOH	887	Saloman (1970)	900	Ca(NbO ₃) ₂	2315	Lapiskii, Nebyhysyn (1961)	—	—	—
KOH	789	Saloman (1970)	804	Fe(TaO ₃) ₂	2502	Lapiskii, Nebyhysyn (1961)	—	—	—
RbOH	766	Yatsimirskii (1956)	773	Metavanadates	—	—	—	—	—
CsOH	721	Yatsimirskii (1956)	724	Li ₂ VO ₄	3945	Golvkin, Fotiev (1970)	—	—	—
Mn(OH) ₂	—	Finch, Gardner (1965)	—	Na ₂ VO ₄	3766	Golvkin, Fotiev (1970)	—	—	—
Fe(OH) ₂	3477	Finch, Gardner (1965)	3629	Ca ₂ Ta ₂ O ₉	3376	Golvkin, Fotiev (1970)	—	—	—
Mg(OH) ₂	2870	Finch, Gardner (1965)	3006	K ₂ VO ₄	3243	Golvkin, Fotiev (1970)	—	—	—
Ca(OH) ₂	2506	Finch, Gardner (1965)	2645	Rb ₂ VO ₄	3137	Golvkin, Fotiev (1970)	—	—	—
Ni(OH) ₂	2330	Finch, Gardner (1965)	2483	Cs ₂ VO ₄	—	—	—	—	—
Pd(OH) ₂	2141	Finch, Gardner (1965)	2339	Nitrates	—	—	—	—	—
Ba(OH) ₂	—	—	2392	LiNO ₃	848	Jenkins, Morris (1977)	—	—	—
Ti(OH) ₃	2909	Wen, Sho (1975)	3008	NANO ₃	748	Jenkins, Morris (1977)	—	—	—
Fe(OH) ₃	2653	Karapet'yants (1954)	3055	KNO ₃	755	Jenkins, Morris (1977)	—	—	—
Co(OH) ₃	2786	Karapet'yants (1954)	3115	RbNO ₃	685	Jenkins, Morris (1977)	—	—	—
Ni(OH) ₃	2832	Karapet'yants (1954)	3193	Cs ₂ NO ₃	662	Jenkins, Morris (1977)	—	—	—
Pt(CuOH) ₂	—	Karapet'yants (1954)	3175	NH ₄ NO ₃	661	Jenkins, Morris (1977)	—	—	—
Cu(CuOH) ₂	2870	Karapet'yants (1954)	3237	—	661	Morris (1958)	—	—	—

Appendix B

Chemistry

JAMES P. BIRK

ARIZONA STATE UNIVERSITY



HOUGHTON MIFFLIN COMPANY

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PALO ALTO

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*To the memory of my father, Albert Birk, who loved
books and who would have enjoyed this one.*

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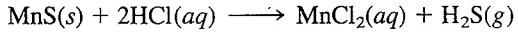
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Table 4.2 Some Solubility Rules for Inorganic Salts in Water

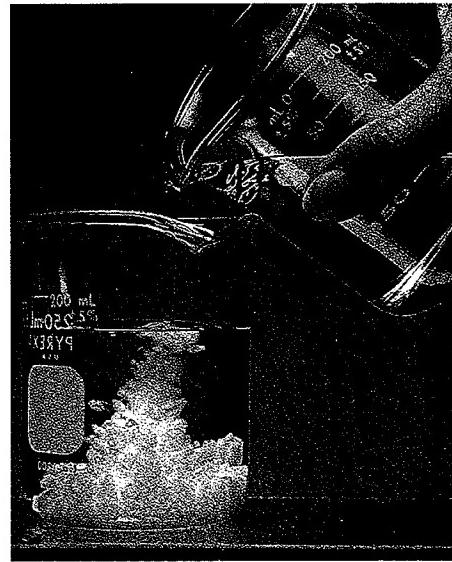
Na^+ , K^+ , NH_4^+	Most salts of sodium, potassium, and ammonium ions are soluble.
NO_3^-	All nitrates are soluble.
SO_4^{2-}	Most sulfates are soluble. Exceptions: BaSO_4 , SrSO_4 , PbSO_4 , CaSO_4 , Hg_2SO_4 , and Ag_2SO_4
Cl^- , Br^- , I^-	Most chlorides, bromides, and iodides are soluble. Exceptions: AgX , Hg_2X_2 , PbX_2 , and HgI_2
Ag^+	Silver salts, except AgNO_3 , are insoluble.
O^{2-} , OH^-	Oxides and hydroxides are insoluble. Exceptions: NaOH , KOH , NH_4OH , $\text{Ba}(\text{OH})_2$, and $\text{Ca}(\text{OH})_2$ (somewhat soluble)
S^{2-}	Sulfides are insoluble. Exceptions: salts of Na^+ , K^+ , NH_4^+ and the alkaline earth metal ions
CrO_4^{2-}	Most chromates are insoluble. Exceptions: salts of K^+ , Na^+ , NH_4^+ , Mg^{2+} , Ca^{2+} , Al^{3+} , and Ni^{2+}
CO_3^{2-} , PO_4^{3-} , SO_3^{2-} , SiO_3^{2-}	Most carbonates, phosphates, sulfites, and silicates are insoluble. Exceptions: salts of K^+ , Na^+ , and NH_4^+

gases, generally binary covalent compounds, are sufficiently insoluble to provide a driving force if they are formed as a reaction product. For example, many sulfide salts will react with acids to form gaseous hydrogen sulfide:



Insoluble gases are often formed by the breakdown of an unstable double-displacement reaction product. For example, carbonates react with acids to form carbonic acid, H_2CO_3 , an unstable substance that readily decomposes into water

Figure 4.11 Left: Soluble barium chloride reacts with soluble sodium sulfate to form insoluble barium sulfate and soluble sodium chloride. **Right:** Barium compounds are extremely toxic, but barium sulfate is so insoluble that people preparing to have their digestive systems X-rayed swallow barium sulfate blended with water to make their digestive system visible to the X rays.



Appendix C



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As a chemical manufacturer serving Analytical Labs worldwide, the addition of product lines targeted directly to that market is one of our top priorities. Hundreds of GFS products fit this product profile, and two groups deserve special mention: ultrapure (99.99 to 99.9999%) materials and standard solutions, and Quaternary Ammonium salts and solutions (QUATS).

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ALIQUAT 175 – Item# 2717

Tributylmethylammonium chloride solution in water.

CETYLTRIMETHYLMONIUM BROMIDE, 98% – Item# 3557**TETRABUTYLAMMONIUM ACETATE 1 M, AQUEOUS – Item# 2515****TETRABUTYLAMMONIUM BOROHYDRIDE, 98% – Item# 2516****TETRABUTYLAMMONIUM BROMIDE REAGENT (ACS) – Item# 353**

Polarographic Grade. A specially purified reagent suitable for supporting electrolyte in polarographic work.

TETRABUTYLAMMONIUM CHLORIDE, 1.0 M AQUEOUS – Item# 2432**TETRABUTYLAMMONIUM CHLORIDE, HYDRATE 98% – Item# 2462****TETRABUTYLAMMONIUM DIHYDROGEN PHOSPHATE – Item# 2433**
99% Crystals**TETRABUTYLAMMONIUM HEXAFLUOROPHOSPHATE – Item# 2435****TETRABUTYLAMMONIUM HYDROGEN SULFATE – Item# 2517****TETRABUTYLAMMONIUM HYDROXIDE 0.4 M AQUEOUS, ELECTROMETRIC GRADE – Item# 2262**
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Methanol solution for HPLC



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TETRABUTYLAMMONIUM HYDROXIDE 1.0 M, REAGENT (ACS), AQUEOUS – Item# 1202

Some solids may be present, which will redissolve upon heating to 40 C in a water bath.

TETRABUTYLAMMONIUM HYDROXIDE 40% AQUEOUS SOLUTION – Item# 2984

Some solids may be present, which will redissolve upon heating to 40 C in a water bath.

TETRABUTYLAMMONIUM HYDROXIDE 55% AQUEOUS – Item# 3575

Some solids may be present, which will redissolve upon heating to 40 C in a water bath.

TETRABUTYLAMMONIUM IODIDE REAGENT – Item# 225

Polarographic Grade. A specially purified reagent suitable for supporting electrolyte in polarographic work at very negative potentials.

TETRABUTYLAMMONIUM PERCHLORATE REAGENT – Item# 394

Tetra-n-butylammonium perchlorate. Suitable for use as polarographic supporting electrolyte.

TETRABUTYLAMMONIUM PHOSPHATE BUFFER, pH 7.5 – Item# 2436

Mixed phosphate buffer. Approximate tetrabutylammonium ion concentration 0.5 M.

TETRABUTYLAMMONIUM TETRAFLUOROBORATE – Item# 2434**TETRABUTYLAMMONIUM TRIFLUOROMETHANESULFONATE – Item# 2518****TETRAETHYLMONIUM ACETATE, 50% AQUEOUS SOLUTION – Item# 2519****TETRAETHYLMONIUM BROMIDE – Item# 1513**

Suitable for use as polarographic electrolyte

TETRAETHYLMONIUM CHLORIDE MONOHYDRATE, 98% – Item# 1514**TETRAETHYLMONIUM HEXAFLUOROPHOSPHATE – Item# 2438**

Not on the TSCA inventory.

TETRAETHYLMONIUM HYDROXIDE, 1.0 M AQUEOUS SOLUTION – Item# 2439**TETRAETHYLMONIUM HYDROXIDE, 20% AQUEOUS SOLUTION – Item# 2520****TETRAETHYLMONIUM IODIDE – Item# 2440****TETRAETHYLMONIUM NITRATE, 35% AQUEOUS – Item# 2522****TETRAETHYLMONIUM PERCHLORATE – Item# 511**

Suitable for use as polarographic supporting electrolyte. Wet with 10% water.

TETRAETHYLMONIUM TETRAFLUOROBORATE – Item# 2437**TETRAHEXYLAMMONIUM IODIDE REAGENT – Item# 366**

(Tetra-n-hexylammonium Iodide) Suitable as supporting electrolyte in polarography.

TETRAHEXYLAMMONIUM PERCHLORATE – Item# 512

(Tetra-n-hexylammonium Perchlorate) suitable for use as a polarographic

supporting electrolyte.

TETRAMETHYLAMMONIUM BROMIDE REAGENT (ACS) – Item# 1515

TETRAMETHYLAMMONIUM CHLORIDE – Item# 1516

TETRAMETHYLAMMONIUM FLUORIDE, TETRAHYDRATE 98% – Item# 2726

TETRAMETHYLAMMONIUM HEXAFLUOROPHOSPHATE – Item# 2442

TETRAMETHYLAMMONIUM HYDROGEN PHTHALATE, 99% – Item# 2524

TETRAMETHYLAMMONIUM HYDROXIDE PENTAHYDRATE – Item# 1680

TETRAMETHYLAMMONIUM HYDROXIDE, SOLUTION 1.0 Mol/L in WATER, REAGENT (ACS) – Item# 2275

TETRAMETHYLAMMONIUM HYDROXIDE, SOLUTION 25% in METHANOL – Item# 2523

TETRAMETHYLAMMONIUM HYDROXIDE, SOLUTION 25% in WATER – Item# 1204

TETRAMETHYLAMMONIUM IODIDE – Item# 2443

TETRAMETHYLAMMONIUM PERCHLORATE – Item# 510

Suitable for use as polargraphic supporting electrolyte.

TETRAMETHYLAMMONIUM SILICATE, 18% AQUEOUS SOLUTION – Item# 2525

Complex mixture of Tetramethylammonium hydroxide and silica in a 1:2 ratio

TETRAMETHYLAMMONIUM TETRAFLUOROBORATE – Item# 2441

TETRAPROPYLAMMONIUM BROMIDE, 98% – Item# 2526

TETRAPROPYLAMMONIUM CHLORIDE, 98% – Item# 2527

TETRAPROPYLAMMONIUM HEXAFLUOROPHOSPHATE – Item# 3500

Not on the TSCA Inventory

TETRAPROPYLAMMONIUM HYDROXIDE, 1 M AQUEOUS SOLUTION – Item# 2528

1 mol/L

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Tetramethylammonium hydroxide

From Wikipedia, the free encyclopedia

Tetramethylammonium hydroxide (TMAH) is a quaternary ammonium salt with the molecular formula $(\text{CH}_3)_4\text{NOH}$. It is used as an anisotropic etchant of silicon. It is also used as a basic solvent in the development of acidic photoresist in the photolithography process.

Toxicity

TMAH solution is a strong base. Its Tetramethylammonium ion can damage nerves and muscles, causing difficulties in breathing and possibly death in a short period of time after exposure by contact even with a small amount.

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Categories: Quaternary ammonium compounds | Organic compound stubs

-
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Appendix D

A Guide to Solvents and Reagents in Introductory Organic Chemistry for students in 2.222

Dr. P.G. Hultin, February 2002

1.	<u>SOLVENTS</u>	1
1.2.	Polar Protic Solvents	1
	<i>Water</i>	1
	<i>Methanol, Ethanol, Isopropanol, Tert-butanol</i>	1
	<i>Acetic Acid</i>	2
1.3.	Polar Aprotic Solvents	2
	<i>Acetone</i>	3
	<i>Dimethylsulfoxide (DMSO)</i>	3
	<i>N,N-Dimethylformamide (DMF)</i>	3
1.4.	Ethers	3
	<i>Ether</i>	3
	<i>Tetrahydrofuran (THF)</i>	4
1.5.	Chlorinated Solvents	4
	<i>Dichloromethane</i>	4
	<i>Chloroform</i>	4
1.6.	Hydrocarbon Solvents	5
1.7.	Amine Solvents	5
	<i>Triethylamine</i>	5
	<i>Pyridine</i>	5
1.8.	Miscellaneous Solvents	6
	<i>Ethyl Acetate (EtOAc)</i>	6
	<i>Acetonitrile</i>	6
2.	<u>REAGENTS</u>	7
2.2.	Bronsted Acids	7
	<i>Inorganic acids</i>	7

<i>Organic acids</i>	7
2.3. Lewis Acids	7
<i>Promoters for electrophilic aromatic substitutions</i>	7
<i>Mercury (II) salts</i>	8
2.4. Electrophiles	8
<i>Alkyl halides</i>	8
<i>Epoxides</i>	8
<i>Aryl diazonium ions</i>	8
<i>Carbonyl groups</i>	9
<i>Thionyl chloride</i>	9
<i>p-Toluenesulfonyl chloride</i>	9
<i>Phosphorus tribromide</i>	9
2.5. Bronsted Bases	10
<i>Hydroxide ion</i>	10
<i>Tetrabutylammonium hydroxide</i>	10
<i>Amide ions</i>	10
<i>Amines</i>	10
2.6. Lewis Bases	11
<i>Alcohols</i>	11
<i>Alkenes</i>	11
<i>Carbonyl groups</i>	11
2.7. Nucleophiles	11
<i>Grignard reagents</i>	11
<i>Organolithium reagents</i>	12
<i>Acetylidy ions</i>	12
<i>Lithium dialkyl cuprates</i>	12
<i>Cyanide ion</i>	12
<i>Azide ion</i>	12
<i>Hydroxide and alkoxide ions</i>	12
<i>Halide ions</i>	12
<i>Phthalimide</i>	12

<i>Phosphines</i>	13
<i>Hydrazine</i>	13
<i>Amines</i>	13
<i>Water and alcohols</i>	13
2.8. Oxidizing Agents	13
<i>Potassium permanganate</i>	13
<i>Osmium tetroxide</i>	14
<i>Halogens</i>	14
<i>Hydrogen peroxide</i>	14
<i>Peroxyacid reagents</i>	14
<i>Ozone</i>	14
<i>Nitrous acid</i>	14
<i>Chromate reagents</i>	14
2.9. Reducing Agents	15
<i>Hydrogen</i>	15
<i>Alkali metals</i>	15
<i>Reducing metal/acid reagents</i>	15
<i>The Wolff-Kishner reduction</i>	15
<i>Hydride donor reagents</i>	15
2.10. Miscellaneous	16
<i>Carbenes and carbenoids</i>	16
<i>Borane and diborane</i>	16

1.6. Hydrocarbon Solvents

Hydrocarbon solvents are generally inert to reagents of all kinds. They are neither acidic nor basic, in either the Lewis or Bronsted senses. They will only dissolve low polarity organics, although the *aromatic solvents* are a bit more tolerant in this regard. Hydrocarbon solvents provide a reaction environment that is as close to the gas phase as a solution can get.

The main factor dictating the choice of one hydrocarbon over another is *boiling point*, if the reaction involves heating, or *melting point*, if the reaction is to be done at low temperature.

Common Aliphatic Solvents: Pentane (mostly isomers of C₅H₁₂, bp 35-36 °C), Hexanes (mostly isomers of C₆H₁₄, bp 69 °C), iso-Octane (2,2,4-trimethylpentane, C₈H₁₈, bp 98-99 °C), and decalin (perhydronaphthalene, C₁₀H₁₈, bp 189-191 °C).

Common Aromatic Solvents: Benzene (C₆H₆) bp 80 °C, Toluene (C₆H₅CH₃) bp 111 °C, and Xylenes (*o,m,p* isomers of C₆H₄(CH₃)₂) bp 140 °C.

Benzene is no longer used as a reaction solvent because of its carcinogenicity. Toluene and Xylenes are much safer and are usually equivalent substitutes.

One of the main uses of aromatic solvents is their ability to remove water by *azeotropic distillation*. For example, the toluene/water azeotrope, boiling at 84 °C, contains 14% water. Reactions that generate water, such as elimination of OH groups or ester formation, can be done in boiling toluene. When the vapour is condensed, the water is not miscible with the toluene and can be removed while the toluene is returned to the reaction vessel.

1.7. Amine Solvents

Several “special purpose” organic solvents are encountered from time to time. The most common of these are the *amines*, which are Bronsted and Lewis bases. Reactions that generate protons are frequently performed in the presence of amine bases, and occasionally the amine is the solvent for the process. The properties of common amines are also discussed under the “Reagents” heading.

Triethylamine (Et₃N, (CH₃CH₂)₃N): MW 101.19, density 0.726 g/mL, mp –115 °C, bp 90 °C.

Triethylamine is miscible with water and with most organics. Thus it has become one of the most common organic bases. It is often used as a reagent or a co-solvent, but it can be used as the solvent for several types of reactions as well. It is unfortunately rather smelly, as are most amines.

Pyridine (Pyr, Error! Objects cannot be created from editing field codes., C₅H₅N): MW 79.102, density 0.983 g/mL, mp –42 °C, bp 115 °C.

Pyridine is an aromatic amine. It is less basic than is triethylamine, but it is quite nucleophilic because the nitrogen lone pair is very exposed. It is used as a solvent for many of the same reactions that triethylamine might be used for. Pyridine is also very soluble in water.